

Title (en)

Method for manufacturing silica glass

Title (de)

Verfahren zum Herstellen von Quarzglas

Title (fr)

Procédé de fabrication du verre de quartz

Publication

**EP 1035078 B1 20060517 (EN)**

Application

**EP 00104522 A 20000310**

Priority

- JP 6325899 A 19990310
- JP 8848899 A 19990330
- JP 9598299 A 19990402

Abstract (en)

[origin: EP1035078A2] An optical member made of silica glass manufactured by the direct method where a material gas comprising an organosilicon compound is allowed to react in an oxidizing flame, said optical member having a  $2 \times 10^{14}$  molecules/cm<sup>3</sup> or less concentration of formyl radical generated by X-ray irradiation whose dose is 0.01 Mrad or more and 1 Mrad or less.

IPC 8 full level

**C03B 19/14** (2006.01); **C03B 8/04** (2006.01); **C03B 19/06** (2006.01); **C03C 3/06** (2006.01); **G03F 7/20** (2006.01)

CPC (source: EP US)

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Cited by

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